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# Porous silicon filled with Pd/WO<sub>3</sub>–ZnO composite thin film for enhanced H<sub>2</sub> gas-sensing performance†

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Here, pure ZnO, WO<sub>3</sub> and Pd/WO<sub>3</sub>–ZnO composite porous thin films were successfully synthesized directly on porous silicon by a reactive DC magnetron sputtering technique. A sensor based on the Pd/WO<sub>3</sub>–ZnO composite porous thin films showed remarkably improved H<sub>2</sub> sensing performance with good stability and excellent selectivity compared to that of pure WO<sub>3</sub> and ZnO, at a relatively lower operating temperature (200 °C) and with a low detection range of 10–1000 ppm. The enhanced response can be attributed to the heterojunction formed between two dissimilar materials. The underlying mechanism behind their good performance for H<sub>2</sub> gas was discussed in detail.

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## 1. Introduction

Hydrogen has been regarded as one of the most promising clean energy sources bearing in mind the zero emission energy fuel and high heat of combustion (142 kJ g<sup>-1</sup>), producing water without any harmful by-products.<sup>1–3</sup> Therefore, the globally growing demand for clean energy has engaged widespread research in the field of H<sub>2</sub> as a future renewable energy resource.<sup>4–7</sup> Nevertheless, hydrogen is colorless, tasteless and odorless with a low ignition energy (0.02 mJ), high diffusion coefficient (0.60 cm<sup>2</sup> s<sup>-1</sup>) and broad flammable range (4–75%) in air which hinders its convenient application.<sup>8–10</sup> Thus, there is an urgent need to realize a reliable, inexpensive and fast response sensor device to detect trace amounts of hydrogen just before the explosive limit, even at low temperature.

Over the past few years, due to human demand, a huge number of materials have been extensively studied and implemented as promising sensing materials to this end. Among the various types of gas sensors, metal oxide semiconductor (MOS) based nanostructured chemiresistive gas sensors have grasped a significant position due to several attractive features such as low cost, simple fabrication, environmental benignity, high sensitivity and selectivity, industrial emission control, biomedical, household security and good compatibility towards microelectronic processes for long range of operations.<sup>11–15</sup> Therefore, the chemiresistive gas sensors have attracted a notable attention of the researchers and become most enthusiastic research area among the scientific community

since 1980s. In the present time, the developing nanotechnology promises incredible improvement in the sensor designing and capabilities. The main objective of this work is to fabricate the nanostructured composite metal oxide based H<sub>2</sub> gas sensors under low detection limit in our environment. Among the other MOSs, WO<sub>3</sub> and ZnO as gas sensing materials offer the promising platform towards the oxidizing as well as reducing gases. Generally, the MOS gas sensors need to be operated at relatively high temperatures (350 °C or higher).<sup>16,17</sup> Wongchoosuk *et al.* fabricated a WO<sub>3</sub> based sensor to detect hydrogen at 350 °C.<sup>18</sup> Therefore, the main emphasis of modern research is on reducing the working temperature of the gas sensors to meet the demand of low power consumption, safety and several industrial applications. Therefore, remarkable efforts have been done to moderate the working temperature (≅200 °C) of gas sensors *via* formation of (n–n or n–p heterojunction at the interface) nanostructured composite material and enlightening the sensing properties by rising the adsorption and desorption rate of analyte gas molecules at the sensor surface.<sup>19,20</sup> This leads to fabrication of the new active sensing material in order to meet the remarkable high sensing performance criteria with fast response, low power consumption, high reproducibility and reliability. Based on these investigations, the Pd decorated WO<sub>3</sub>–ZnO composite thin films may be fabricated as fast response gas sensors which can be recognized to detect low concentration (ppm) of hydrogen in storage and sensing device applications. Among the various approaches, reactive DC sputtering has been considered as an effective technique for the fabrication of high quality contamination free, highly uniform and stoichiometric growth of the composite nanostructures.<sup>21</sup>

For chemiresistive gas sensors, the sensing mechanism strongly depends on the change in the resistance caused by strong adsorption and effective diffusion of the analyte gas

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molecules exposed over the top surface of nanostructured composite materials.<sup>10,22</sup> Recently, the performance of the gas sensor predominantly depends on various factors such as the surface morphology, crystal structure, composition of the sensing material, porosity and exposed surface area.<sup>23,24</sup> Therefore, the synthesis of nanostructured materials having large surface area with high porosity has been attributed to explore and innovate the new functional materials for highly sensitive and fast response gas sensors.<sup>25,26</sup>

In the present work, we demonstrated the highly porous bare ZnO, WO<sub>3</sub> and Pd/WO<sub>3</sub>-ZnO composite sensors on the hydrophobic porous silicon substrates fabricated by reactive magnetron DC sputtering technique. Herein, the hydrogen sensing properties of prepared ZnO, WO<sub>3</sub> and Pd/WO<sub>3</sub>-ZnO composite microspheres for an working temperature range of (30–350 °C) under the low detection limit (10–1000 ppm) have been studied in detail. Furthermore, we have studied the variation in the response for hydrogen under several humidity conditions (0–90% RH) at the optimum temperature (200 °C). In addition, we expect that the role of hydrophobic nature of porous silicon substrate established the drastic improvement in stability and recovery process towards H<sub>2</sub> sensing thin films. Therefore, this work may provide a new insight into gas sensing mechanism and opens up a promising way to fabricate the low temperature gas sensors.<sup>27</sup>

## 2. Experimental

### 2.1 Materials and chemicals

Tungsten (W) and zinc (Zn) targets of (2" diameter, 5 mm thickness) with high purity (99.99%) were purchased from (Testbourne Ltd. UK). The hydrofluoric acid (48%) and ethanol solution were obtained from Merck, India. The p-type (100) oriented silicon wafers (0.68 mm thick, 15–20 Ω cm) were purchased from Bayville Chem, USA.

### 2.2 Sensor fabrication

The synthesis of porous silicon (PS) substrates was already discussed in authors' previous study.<sup>28</sup> Porous silicon can be formed either nanoporous or macroporous structures depending on the formation parameters and the forming solution. It's usually different structures exhibit very high surface to volume ratio, ease of fabrication and compatibility to silicon IC technology leading to smart sensors have been fascinating the researchers worldwide for more than a decade.<sup>29,30</sup> Macroporous silicon is one of the most promising candidate for the fabrication of numerous gas sensors.<sup>31,32</sup> Herein, we fabricate the porous silicon using electrochemical anodization and it significantly enhance the active surface area for adsorption of analyte gas molecules.<sup>33,34</sup> The porous silicon substrates provide the base for the composite material to grow in dome like shape and helps to trap the gas molecules between the gaps. This leads to high sensitivity of the sensing device. After anodization, the fabrication process of sensing material was systematically carried out in a custom designed (12" diameter) sputtering chamber (Excel Instruments) using high purity (99.99%) W, Zn

and Pd sputter targets (2" diameter, 5 mm thick). Prior to deposition, the prepared PS substrates were rinsed in deionized water and kept inside the chamber at fix distance of 6 cm from the W and Zn targets. The bare ZnO, WO<sub>3</sub> and Pd decorated WO<sub>3</sub>-ZnO composite samples were sputtered on the porous silicon substrates using reactive DC magnetron sputtering technique. During all depositions, the synthesis temperature, pressure and time were maintained at room temperature, 10 mTorr and 45 minutes respectively, with continuous flow of high purity (99.99%) Ar : O<sub>2</sub> (4 : 1) using mass flow controller (MKS). Firstly, the bare WO<sub>3</sub> and ZnO thin films were fabricated on porous silicon substrates using the sputtering power of 60 W and 50 W, respectively. Thereafter, the varied composition ratio of WO<sub>3</sub> : ZnO (1 : 1, 1 : 2, and 2 : 1) have been fabricated on the porous silicon by co-sputtering the W and Zn targets simultaneously for a time period of 45 minutes using varying the sputtering power of 50–70 W and 45–65 W, respectively.<sup>35</sup> Later on, the Pd layer of small thickness (~5 nm) was deposited on WO<sub>3</sub>-ZnO (1 : 1) composite thin films for a period of 3–5 seconds using working power and pressure of 30 W and 5 mT respectively, with Ar gas flow rate of 20 sccm. To measure the electrical resistance, the device schematic view of the Pd/WO<sub>3</sub>-ZnO composite sensor is demonstrated in Fig. S-4.† Herein, the composite sample nominated as "Pd/WO<sub>3</sub>-ZnO" right through in the manuscript indicates the one of WO<sub>3</sub>-ZnO (1 : 1).

### 2.3 Characterization

The X-ray diffraction (XRD) patterns of as deposited bare WO<sub>3</sub> and Pd/WO<sub>3</sub>-ZnO (1 : 1) composite thin films were characterized using X-ray diffractometer (Bruker AXS, D8 advance) in ( $\theta$ - $2\theta$ ) geometry with CuK <sub>$\alpha$</sub>  radiation ( $\lambda = 1.5418 \text{ \AA}$ ). The surface microstructure and cross-section view of the both thin films were investigated using field emission scanning electron microscopy (FESEM, Carl Zeiss, Ultra Plus). The elemental composition and mapping analysis of these samples were examined using an energy dispersive spectroscopy analysis (EDS, Oxford Instruments). The Raman spectra of Pd/WO<sub>3</sub>-ZnO composite was recorded using Raman spectroscopy (Renishaw, United Kingdom) using 514 nm laser as an excitation wavelength. The change in electrical resistance of ZnO, WO<sub>3</sub> and Pd/WO<sub>3</sub>-ZnO thin films synthesized on porous silicon were studied in a custom designed sensing setup (volume of 300 cm<sup>3</sup>) equipped with PID controlled electric heater with two probe system using source meter (Keithley 2400) and a nanovoltmeter (Keithley 2182 A).<sup>36</sup> The schematic representation of the gas sensing test setup is described in authors' previous study. Prior to sensing test, the sensing chamber was evacuated to  $3 \times 10^{-1}$  Torr using mechanical rotary vacuum pump. Thereafter, the mixed ratio of highly pure H<sub>2</sub> and synthetic air was introduced inside the sensing chamber at different humidity conditions. The mixed gas flow rate of 50 cm<sup>3</sup> min<sup>-1</sup> was controlled using mass flow controller (MKS, USA). The sensor response is defined as the ratio of the device resistance in synthetic air ( $R_a$ ) to the gas resistance ( $R_g$ ) after exposure to hydrogen gas molecules. The response and recovery time is defined as the elapsed time to reach the signal up to 90% change of the total saturated



sensing response during adsorption and desorption process, respectively.<sup>37</sup> Moreover, all hydrogen sensing measurements were repeated four times and about 3% variation in the sensing properties was observed.

### 3. Result and discussion

#### 3.1 Structural properties

Fig. 1a depicts the XRD patterns of bare  $\text{WO}_3$  and  $\text{Pd}/\text{WO}_3\text{-ZnO}$  composite thin films consists of monoclinic phase of  $\text{WO}_3$  corresponding to (011), (320) and (160) planes at  $26.12^\circ$ ,  $44.42^\circ$  and  $77.42^\circ$  (JCPDS ICDD no. 00-005-0364). The  $\text{Pd}/\text{WO}_3\text{-ZnO}$  composite thin film also consists of hexagonal phase of  $\text{ZnO}$  corresponding to (100) and (101) planes at  $31.72^\circ$  and  $36.35^\circ$  (JCPDS ICDD no. 00-003-0888). In addition, Fig. 1a shows the cubic phase of Si corresponding to (311) plane at  $56.72^\circ$  (JCPDS ICDD no. 00-002-0561). Here, no any XRD peak of Pd was detected due to small thickness ( $\sim 5$  nm) of Pd in comparison to  $\text{WO}_3\text{-ZnO}$  composite layer.

A room temperature Raman spectra of as deposited  $\text{Pd}/\text{WO}_3\text{-ZnO}$  composite layer was recorded to reveal more about the structural properties of the thin film. Fig. 1b depicts the Raman spectra of  $\text{Pd}/\text{WO}_3\text{-ZnO}$  composite thin film from  $100\text{-}1200\text{ cm}^{-1}$  to determine the phase of the sensing layer. The Raman spectrum of the sample demonstrates the vibrational peaks at  $278$ ,  $438$ ,  $574$ ,  $812$  and  $950\text{ cm}^{-1}$ . In this spectrum, the strongest band at  $272\text{ cm}^{-1}$  assigned to the bending vibration modes of  $\text{O-W}^{5+}\text{-O}$  indicate the existence of oxygen vacancies.<sup>38</sup> The band observed at  $812\text{ cm}^{-1}$  corresponds to the bridging stretching modes of  $\text{O-W}^{6+}\text{-O}$ .<sup>39</sup> Furthermore, the peak at  $950\text{ cm}^{-1}$  can be attributed to the stretching modes of  $\text{W}^{6+}=\text{O}$  terminal.<sup>38</sup> On the other hand, the peak observed at  $438\text{ cm}^{-1}$  was assigned as  $\text{E}_2$  band which belongs to wurtzite structure of zinc oxide. The  $\text{E}_2$  peak is often associated to the oxygen atoms only. The  $\text{A}_1$  (LO) mode at  $574\text{ cm}^{-1}$  denotes the polar mode of vibrations of Zn and O atoms of ZnO which can be ascribed to the deficiency of oxygen vacancies in ZnO matrix.<sup>40</sup> These result demonstrates that the structure of tungsten oxide and zinc oxide can be well indexed corresponding to a monoclinic and hexagonal phase

respectively. Therefore, the observed Raman spectrum is well consistent with the XRD results.

Fig. 2a and b depicts the FE-SEM images and corresponding cross-section view of as deposited bare  $\text{WO}_3$  and  $\text{Pd}/\text{WO}_3\text{-ZnO}$  composite sensing layers. The porous silicon substrate ( $12\text{ }\mu\text{m}$  depth,  $3\text{ }\mu\text{m}$  width) were filled with the bare  $\text{WO}_3$  composite layer of  $\text{Pd}/\text{WO}_3\text{-ZnO}$ . The uniform and homogeneously distributed grain growth of  $\text{WO}_3$  and  $\text{Pd}/\text{WO}_3\text{-ZnO}$  composite samples indicating the porous and dense packing microstructure with good monodispersity that collaborate to the low temperature fabrication of sensing thin films. The compositional study of bare  $\text{WO}_3$  and  $\text{Pd}/\text{WO}_3\text{-ZnO}$  composite sensing film was examined using EDAX measurements, as shown in Fig. 2c and d. Only four elements, W, Zn, O and Pd are identified in this spectrum. The FE-SEM micrograph and EDS analyses of pure ZnO sample is shown in Fig. S1.† In addition, Fig. 3 depicts the mapping analysis of top view of  $\text{Pd}/\text{WO}_3\text{-ZnO}$  composite sensing layer. Similarly, Fig. 4 shows the elemental mapping analysis of cross-sectional cut of  $\text{Pd}/\text{WO}_3\text{-ZnO}$  composite sensing layer. These results reveal that all the elements are uniformly distributed inside the silicon pores. Therefore, it may be inferred that the  $\text{Pd}/\text{WO}_3\text{-ZnO}$  composite sensor on porous silicon can absorb and desorb the  $\text{H}_2$  reversibly for a long time.

#### 3.2 Sensing performance

Fig. 5a depicts the gas response curve of  $\text{WO}_3\text{-ZnO}$  (2 : 1),  $\text{WO}_3\text{-ZnO}$  (1 : 1) and  $\text{WO}_3\text{-ZnO}$  (1 : 2) thin film sensors as a function of operating temperature to  $100\text{ ppm H}_2$  in dry air. Here, we observed that the  $\text{WO}_3\text{-ZnO}$  (1 : 1) sensor exhibit the highest response due to same at% of W and Zn elements present in the sensing layer towards  $100\text{ ppm H}_2$  at  $200\text{ }^\circ\text{C}$ . However,  $\text{WO}_3\text{-ZnO}$  (2 : 1) and  $\text{WO}_3\text{-ZnO}$  (1 : 2) thin film sensors exhibit the highest response at  $250\text{ }^\circ\text{C}$ . Due to formation of the hetero-junction between two dissimilar materials the composite gas sensors will have better sensing performances than those of their individual components alone. It is customary that the sensor response will significantly depends on the elemental composition. In addition, the composite sensor exhibits the

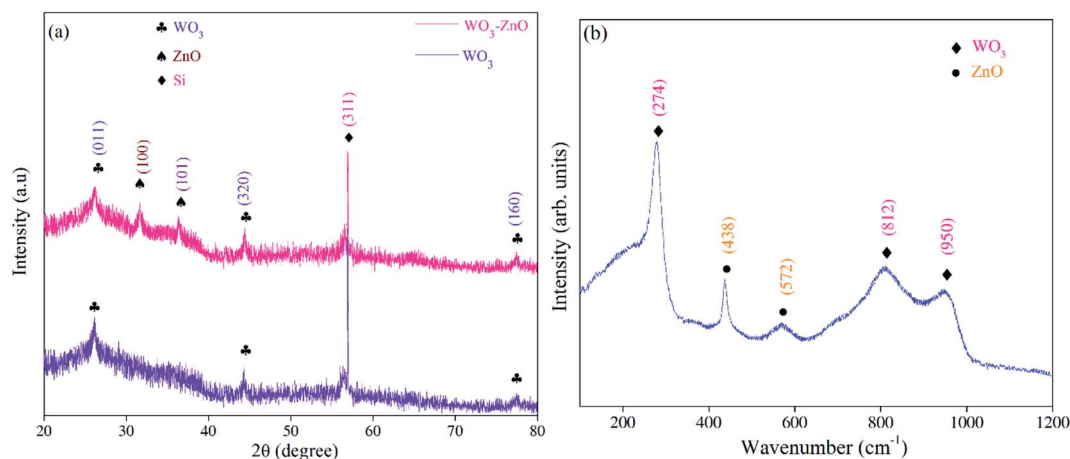


Fig. 1 (a) XRD spectra of  $\text{WO}_3$  and  $\text{Pd}/\text{WO}_3\text{-ZnO}$  thin films, and (b) Raman spectra of  $\text{Pd}/\text{WO}_3\text{-ZnO}$  thin film.



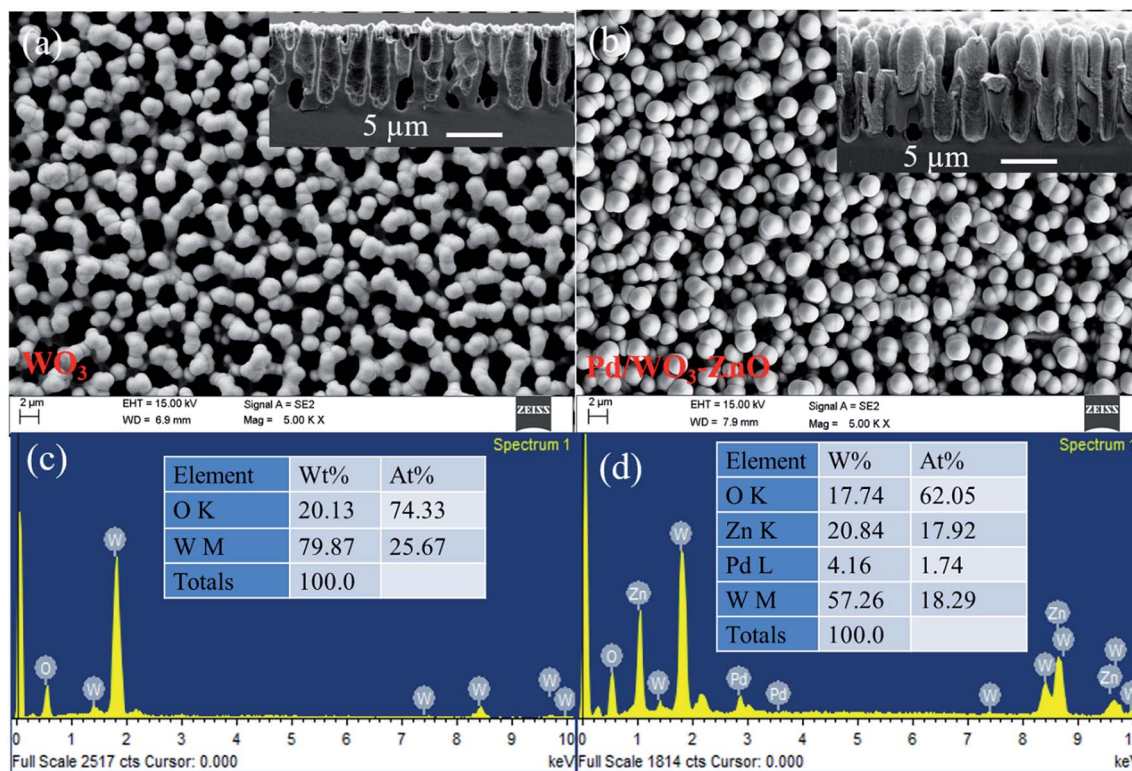


Fig. 2 (a and b) FE-SEM images with corresponding cross section images, and (c and d) EDS spectra of WO<sub>3</sub> and Pd/WO<sub>3</sub>-ZnO thin films, respectively.

maximum response only when the catalytic action of the present components counterpart to each other.<sup>23</sup> Therefore, WO<sub>3</sub>-ZnO (1 : 1) can show the best sensor response due to complement catalytic reaction of WO<sub>3</sub> and ZnO would take place at about equal elemental compositions. It might be due to more activation sites are available on WO<sub>3</sub>-ZnO (1 : 1) composite surface for oxygen adsorption at 200 °C. Thus, we have to choose WO<sub>3</sub>-ZnO (1 : 1) for further analysis through. Furthermore, we varied the Pd concentration from 0.97 at% to 2.95 at%. The result shows that the response increases with the Pd concentration up to 1.74 at%. Thereafter, response starts to decline as Pd concentration further increases to 2.95 at% [see Fig. S2(c)†]. It can be due to reduce the magnitude of activated sites on WO<sub>3</sub>-ZnO composite surface for oxygen adsorption as the number of attached Pd nanoparticles increases, and *vice versa*.<sup>41,42</sup> Thereafter, the variation in the sensor response of bare ZnO, WO<sub>3</sub> and Pd/WO<sub>3</sub>-ZnO (1 : 1) composite gas sensors was investigated at different operating temperatures to 100 ppm H<sub>2</sub> in synthetic air (Fig. 5b). It can be observed that the gas sensors reveal the noticeable rise in the sensing response with rising the operating temperature. Meanwhile, the response turns to decline gradually if we further increase the temperature. Initially, it might be observed due to slow chemical activation between adsorbed analyte gas molecules and sensor surface at low temperatures.<sup>43</sup> However, upon exposure to analyte gas the adsorbed gas molecules might be escape before reactions take place on the sensor surface at too high operating temperatures and hence the poor response as well.<sup>43</sup> Based on

these investigations, bare ZnO and WO<sub>3</sub> sensors depict the maximum response at 300 °C and 250 °C, respectively, while for Pd/WO<sub>3</sub>-ZnO composite sensor the sensing response seems to be maximum at 200 °C (Fig. 5b). It indicates that the Pd/WO<sub>3</sub>-ZnO composite sensor depicts the high response to H<sub>2</sub> as compare to bare ZnO and WO<sub>3</sub> sensor through the whole temperature regime.<sup>44</sup> This could be due to increase in the number of charge carriers in the depletion layer at the heterojunction, leading to remarkable enhance the response. Fig. 5c shows the sensing response characteristics of Pd/WO<sub>3</sub>-ZnO composite gas sensors upon exposure to the various concentration of H<sub>2</sub> in synthetic air. These results reveals that the gas sensor might be able to detect the trace amount of hydrogen down to 10 ppm and exhibit a high response in the range of 10–1000 ppm at 200 °C. Fig. 5d depicts that Pd/WO<sub>3</sub>-ZnO composite sensor exhibit the stable response over 20 cycles towards 100 ppm of H<sub>2</sub> at 200 °C. It indicates that the composite thin films exhibit the excellent repeatability to 100 H<sub>2</sub> at 200 °C. The response and recovery time curves at various H<sub>2</sub> concentrations were investigated in the range of 10–1000 ppm at 200 °C (Fig. 6a). For Pd/WO<sub>3</sub>-ZnO composite gas sensor, the fast response and recovery time was achieved to be 16 s and 62 s respectively towards 100 ppm H<sub>2</sub> at 200 °C. The diffusion-limited kinetics at low hydrogen concentration can be attributed to achieve the high response time with reducing the target gas concentration.<sup>3</sup> Fig. 6b depicts the *I*-*V* characteristics of the Pd/WO<sub>3</sub>-ZnO composite sensor, exhibits the rectifying diode behavior in absence/presence of hydrogen (100 ppm) at 200 °C.



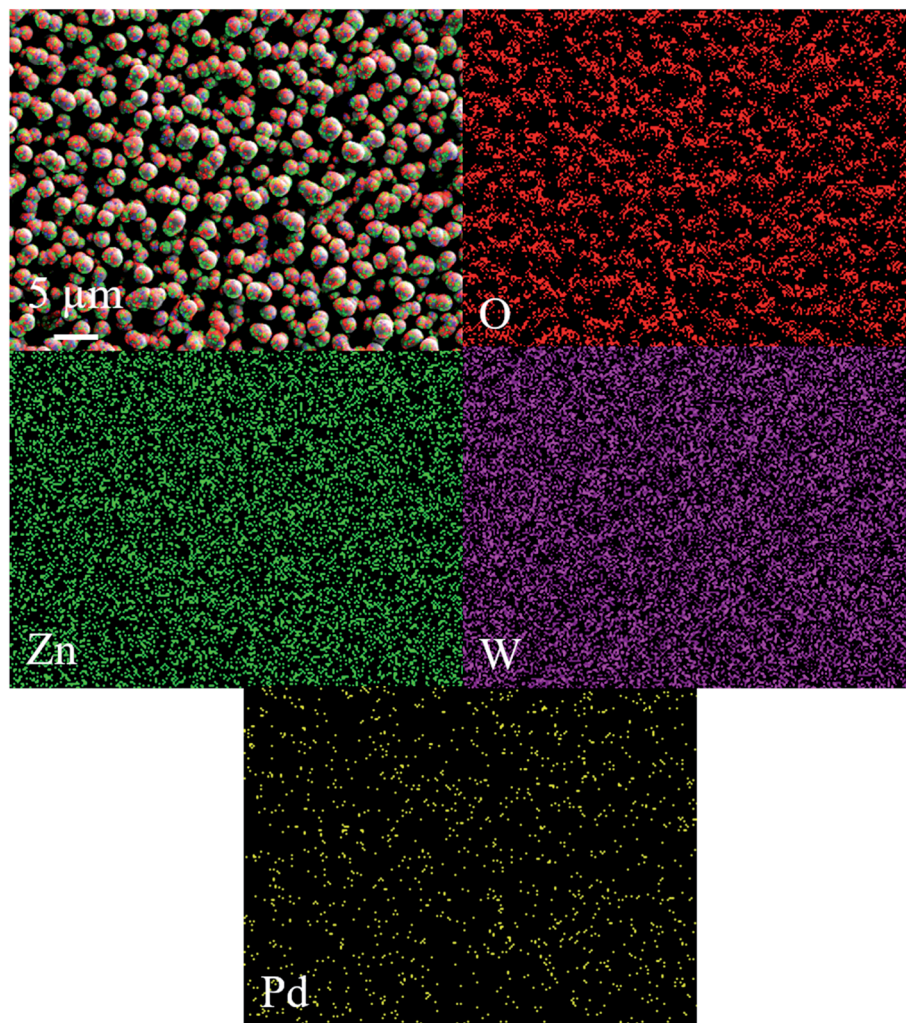


Fig. 3 Elemental mapping of surface images of Pd/WO<sub>3</sub>-ZnO thin film.

As shown in Fig. 6c, the selectivity of the sensors was also measured towards H<sub>2</sub> gas with respect to other potentially hazardous gases such as carbon monoxide (CO), hydrogen

sulfide (H<sub>2</sub>S) and ammonia (NH<sub>3</sub>) upon exposure to 100 ppm concentration at 200 °C. The Pd/WO<sub>3</sub>-ZnO composite sensor exhibited a remarkably high response ( $R_a/R_g = 16.8 \pm 0.2$ )

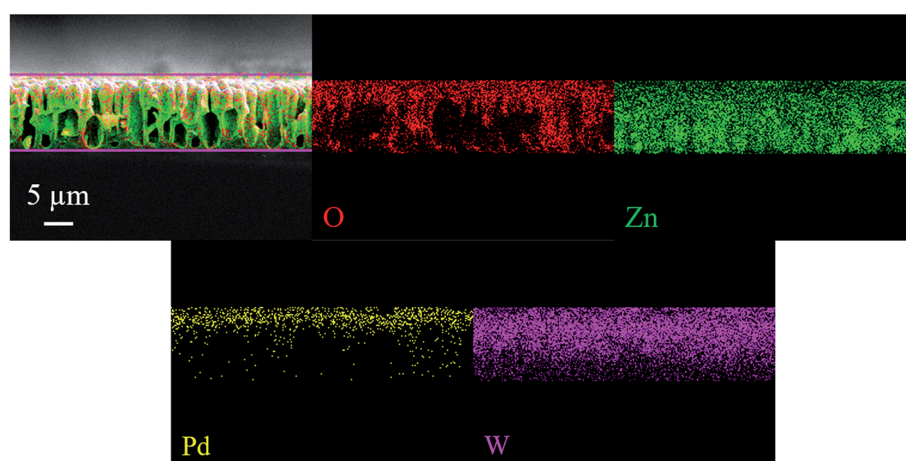


Fig. 4 Elemental mapping of cross sectional images of Pd/WO<sub>3</sub>-ZnO thin film.



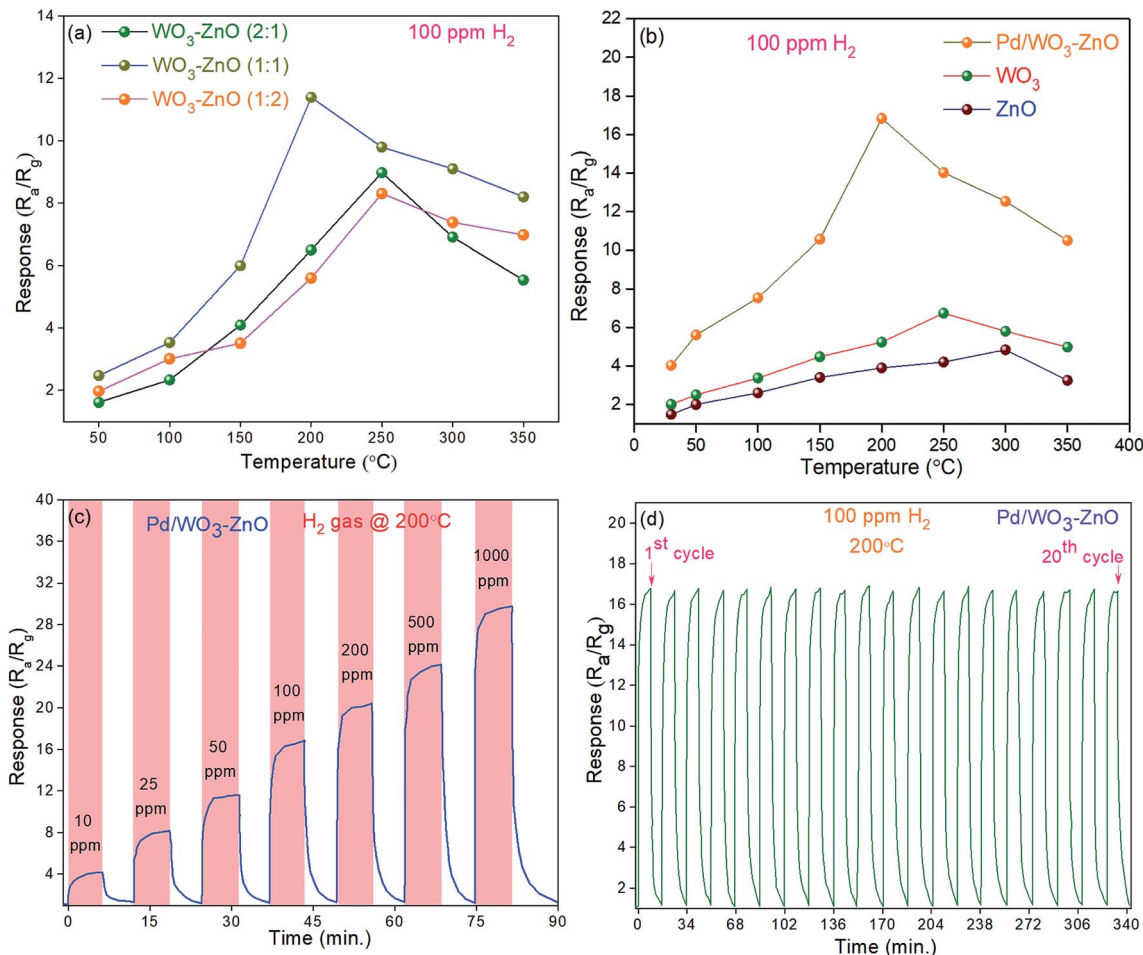


Fig. 5 (a) Gas response curve of  $\text{WO}_3\text{-ZnO}$  (2 : 1),  $\text{WO}_3\text{-ZnO}$  (1 : 1) and  $\text{WO}_3\text{-ZnO}$  (1 : 2) thin film sensors as a function of operating temperature to 100 ppm  $\text{H}_2$  in dry air, (b) gas response curve of the bare ZnO,  $\text{WO}_3$  and Pd/ $\text{WO}_3\text{-ZnO}$  (1 : 1) thin film sensor vs. operating temperatures to 100 ppm  $\text{H}_2$  gas in dry air, (c) gas response curve of Pd/ $\text{WO}_3\text{-ZnO}$  thin film sensor as a function of the hydrogen concentration (10–1000 ppm) at 200 °C in dry air, (d) cyclic response curve of Pd/ $\text{WO}_3\text{-ZnO}$  thin film sensor towards  $\text{H}_2$  with a gas concentration of 100 ppm at 200 °C in dry air.

towards  $\text{H}_2$  and a weak response ( $R_a/R_g < 4.5 \pm 0.3$ ) with respect to other potentially interfering gases. This result shows that the Pd/ $\text{WO}_3\text{-ZnO}$  sensor is highly selective towards  $\text{H}_2$  gas. The effect of moisture on the sensing response was examined under different humidity (0–90%) conditions towards 100 ppm  $\text{H}_2$  in synthetic air at 200 °C (Fig. 6d). This result indicates that about 15% decline in the response was observed for Pd/ $\text{WO}_3\text{-ZnO}$  composite gas sensor. It can be explained as follows: when the active layer is exposed to a mixed gas, more water molecules get adsorbed on the sensor surface under high humidity conditions. Thereafter, the reaction between the water molecules and surface oxygen species deteriorated which contributes to a fall in baseline resistance of the sensor and consequences in a decrease of its sensitivity.<sup>45</sup> It can be due to the water vapors declining the sensor response by preventing the adsorption of target gas molecules on the sensor surface. Therefore, the change in sensor response and baseline resistance is mostly accredited to the high adsorption of water molecules on the top surface of the sensing layer in humid environment.<sup>46</sup> Moreover, the response/recovery time *versus* relative humidity tests were

also performed towards 100 ppm  $\text{H}_2$  gas in various humid conditions (dry air to 90% RH). At the same  $\text{H}_2$  concentration, results depict that the response and recovery time continuously rise with increasing RH (see Fig. S-3†). It may be due to the water molecules acting as a barrier against the  $\text{H}_2$  adsorption and hence the migration of  $\text{H}_2$  molecules on the composite surface becomes rather difficult.<sup>47</sup> Thus, the response and recovery of the proposed sensor to the mixed environment of  $\text{H}_2$  with dry air is rather faster than that of  $\text{H}_2$  with humidity. Furthermore, the stability test of the sensor was carried out at 100 ppm  $\text{H}_2$  concentration for four months (Fig. 6e). During the measurements, it indicates a nearly constant response ( $\sim 5\%$  change), demonstrating the remarkable long-term stability of the composite sensor. The decrease in response may be due to heating the active sensing material after long-time working at 200 °C temperature.<sup>48</sup> Moreover, we have used porous silicon substrates to manipulate the structure of the oxide films and enhance the active surface area for the analyte gas molecules (high surface to volume ratio).<sup>32,33</sup> Furthermore, the porous silicon may provide the reproducibility as well as long-term



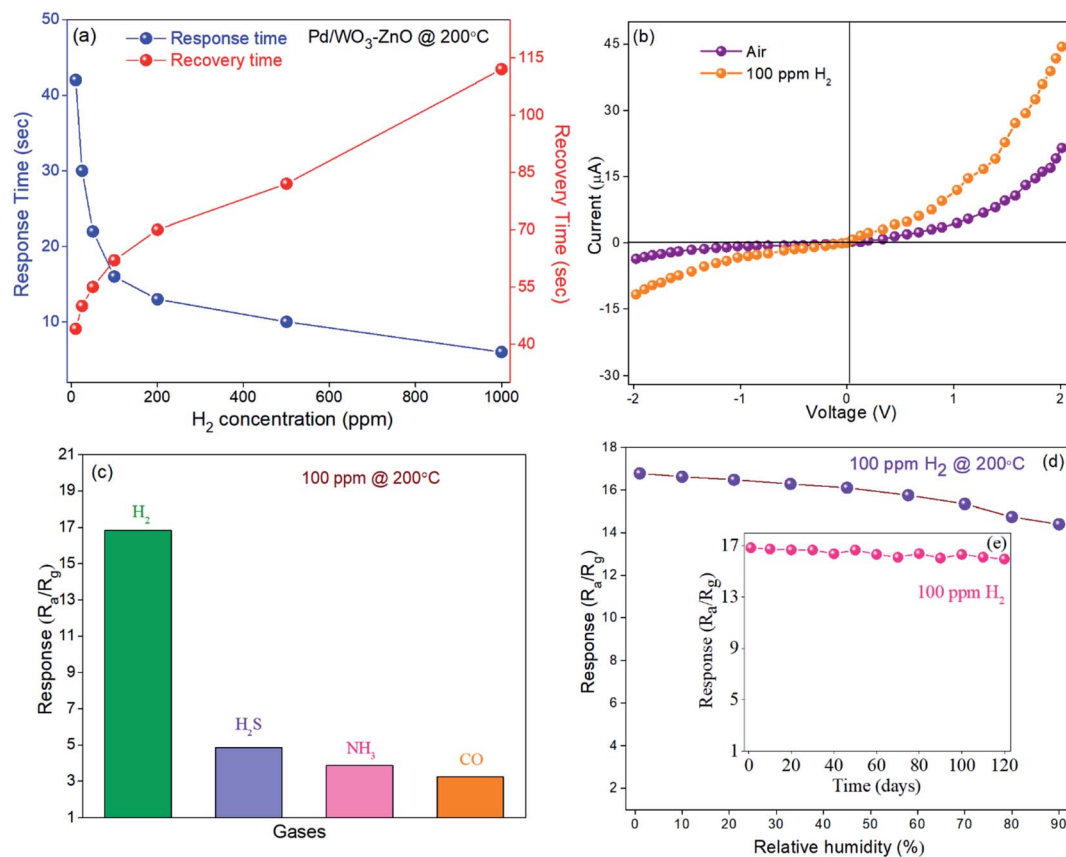


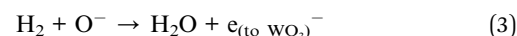
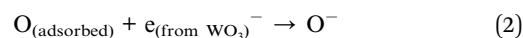
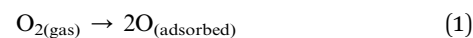
Fig. 6 (a) Response–recovery time curve of the Pd/WO<sub>3</sub>-ZnO (1 : 1) thin film sensor vs. H<sub>2</sub> gas concentrations in dry air, (b) *I*–*V* curve of the Pd/WO<sub>3</sub>-ZnO (1 : 1) thin film sensor in 100 ppm H<sub>2</sub> gas and dry air, (c) cross sensitivity curve of Pd/WO<sub>3</sub>-ZnO thin film sensor towards H<sub>2</sub>, CO, H<sub>2</sub>S and NH<sub>3</sub> with a gas concentration of 100 ppm at 200 °C in dry air, (d) gas response curve of Pd/WO<sub>3</sub>-ZnO (1 : 1) thin film sensor as a function of the relative humidity in 100 ppm H<sub>2</sub> at 200 °C, (e) stability curve of the Pd/WO<sub>3</sub>-ZnO (1 : 1) thin film sensor in 100 ppm H<sub>2</sub> gas concentration in dry air at 200 °C.

stability towards H<sub>2</sub> gas at 200 °C. Therefore, the Pd/WO<sub>3</sub>-ZnO composite thin film sensor is used for detecting the trace amount (10–1000 ppm) of H<sub>2</sub> gas under harsh environment. The hydrogen sensing measurements were repeated four times and about 3% variation in the sensing properties was detected. Moreover, the proposed sensor can be established as a promising candidate for H<sub>2</sub> sensing device application. The comparison of the WO<sub>3</sub> and ZnO sensor systems for H<sub>2</sub> gas is shown in Table S1.†

### 3.3 Sensing mechanism

The basic reaction mechanism of n-type semiconductor sensors has been well documented using depletion layer or space charge model.<sup>49–51</sup> Generally, the adsorption and desorption process of analyte gas molecules on the sensor surface played the prominent role in changing the resistance of sensor device. Therefore, the basic working principle of bare WO<sub>3</sub> layer towards H<sub>2</sub> involves the following steps: firstly, the oxygen molecules present in air environment can adsorbed on the top surface of WO<sub>3</sub> and extract the electron from the conduction band of WO<sub>3</sub>, leading to reduce the electron concentration and hence the initial resistance increases.<sup>52</sup> Secondly, when these chemisorbed oxygen species react with the H<sub>2</sub> molecules, releasing

the electron back to the conduction band of WO<sub>3</sub>, thereby increasing the electron conductivity caused to declines in resistance of sensing thin film.



But the sensor working mechanism of WO<sub>3</sub>-ZnO composite becomes rather different from the bare WO<sub>3</sub> or ZnO oxide layer. In WO<sub>3</sub>-ZnO composite layer, heterojunctions are created at the grain boundaries between WO<sub>3</sub> and ZnO which can significantly contribute to the reducing gas effect in oxide composite materials. It might be due to the formation of n–n heterojunction between two dissimilar materials n-ZnO and n-WO<sub>3</sub> having different work function of 4.41 eV and 5.2 eV respectively.<sup>53,54</sup> The value of energy band gap for ZnO and WO<sub>3</sub> are about 3.3 eV and 2.7 eV, respectively.<sup>55</sup> When two dissimilar materials WO<sub>3</sub> and ZnO formed an electrical connection at the interface, then the electrons will start to flow from high energy conduction band to the lower energy conduction band (from WO<sub>3</sub> to ZnO) until the Fermi levels have equilibrated. Due to lower work



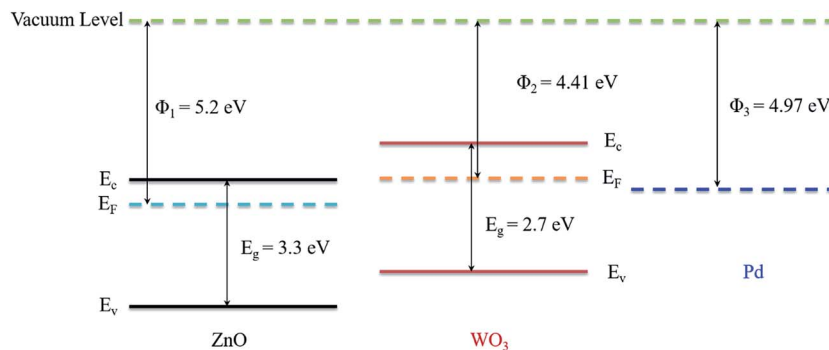


Fig. 7 Energy band diagram of Pd/WO<sub>3</sub>-ZnO thin film sensor before thermal equilibrium.

function of WO<sub>3</sub>, a depletion region is created towards WO<sub>3</sub> at the n-n heterostructures interface whereas an accumulation region is formed towards ZnO caused by transfer the electrons from WO<sub>3</sub> to ZnO. This results in bending the energy band at the WO<sub>3</sub>/ZnO heterojunction which leads to higher resistance state of the sensing material than bare WO<sub>3</sub>.<sup>56</sup> In ambient air, the oxygen species adsorbed at the grain boundaries of WO<sub>3</sub> and ZnO and shield the WO<sub>3</sub>/ZnO heterojunctions such that the conducting electrons being trapped, and the composite layer become more resistive.<sup>55,57</sup> This results to create the barrier height at the WO<sub>3</sub>/ZnO heterojunction. Thereafter, the exposed H<sub>2</sub> gas molecules will reduce the adsorbed oxygen species on the surface. It can be suggested that due to surface reaction the electrons will be generated and flow along the WO<sub>3</sub>/ZnO interfaces, resulting in shrinkage of the electron-depletion layer and barrier height between ZnO and WO<sub>3</sub>. This result to decreases the overall sensor resistance, when a reducing gas is supplied.

Furthermore, when Pd nanoparticles were decorated on the WO<sub>3</sub>-ZnO (1 : 1) sensor surface, the electron starts to flow from WO<sub>3</sub> to Pd nanoparticles, which leads to expand the depletion layer towards WO<sub>3</sub>. As we know the work function of Pd is 4.97 eV. This will further enhance the device resistance of WO<sub>3</sub>-ZnO (1 : 1) composite sensor. Moreover, the thin layer of Pd nanoparticles on the WO<sub>3</sub>-ZnO (1 : 1) sensor surface can easily

dissociate the H<sub>2</sub> molecules into H<sub>ads</sub><sup>+</sup> ions *via* catalytic reaction.<sup>58</sup> Thereafter, a band bending occurs due to difference in Fermi levels of the materials, leads to a formation of potential energy barrier at the interface.<sup>59</sup> This process can facilitates the significant adsorption of oxygen species on the Pd/WO<sub>3</sub>-ZnO sensor surface thereby improving the charge transfer dynamics between the analyte gas molecules and the sensor surface. This enhances the initial device resistance of the Pd/WO<sub>3</sub>-ZnO composite sensor. Fig. 7 show the energy band diagram of the mechanism involved at the Pd/WO<sub>3</sub>-ZnO heterojunctions. In addition, the banding diagram of the Pd/WO<sub>3</sub>-ZnO sensor which establish the bending of the band after the equalization of the Fermi level is illustrated in Fig. 8. Therefore, it is suggested that the conduction band near the boundaries will bend upward, increasing the energy difference between the Fermi level and conduction band.

Owing to the contribution of n-n heterojunction, the enhancement in the sensing response of Pd/WO<sub>3</sub>-ZnO composite towards H<sub>2</sub> gas is noteworthy. The main contributing mechanisms involved at n-n junction is following: the adsorbed oxygen ions react with the exposed reducing H<sub>2</sub> gas molecules on the Pd/WO<sub>3</sub>-ZnO hetero-junction sensor surface and releasing the electron back to the Pd/WO<sub>3</sub>-ZnO composite layer. This result to decreases the overall sensor resistance, when

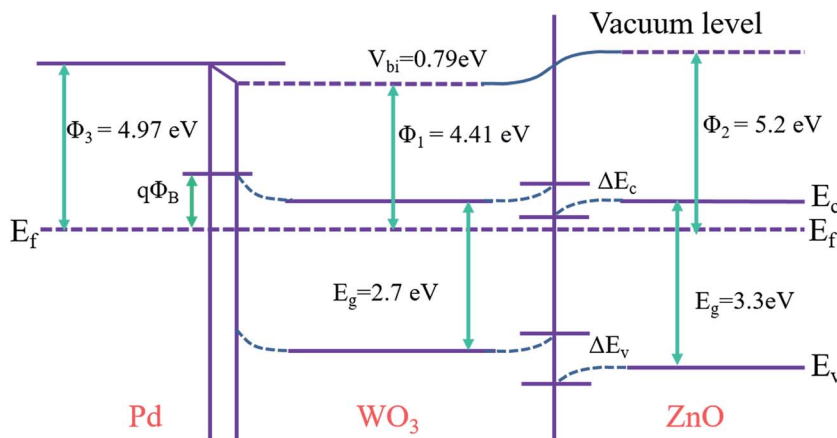


Fig. 8 The energy banding diagram of the Pd/WO<sub>3</sub>-ZnO sensor which establish the bending of the band after the equalization of the Fermi levels.



a reducing gas is supplied. Furthermore, during the recovery process, in absence of H<sub>2</sub> gas the electron concentration on the junction declines, caused to recover the original resistance of the sensor.

## 4. Conclusion

In summary, we have synthesized a bare ZnO, WO<sub>3</sub> and Pd/WO<sub>3</sub>-ZnO composite heterostructures on porous silicon substrates using reactive DC sputtering technique and their sensing properties towards H<sub>2</sub> was investigated in detail. At low temperature, the excellent hydrogen sensing behavior of Pd/WO<sub>3</sub>-ZnO composite sensor is attributed to the formation of n-n heterojunction at the interface. Here, the formation of depletion layer at the n-n heterojunction significantly enhances the sensor response in comparison with a bare ZnO and WO<sub>3</sub> sensors. Such gas sensor can exhibit high response ( $R_a/R_g \sim 16.8$ ) with fast response time (16 s) and good selectivity to 100 ppm H<sub>2</sub> at 200 °C. This study has also demonstrated the highly stable (120 days) and reproducible (20th cycles) sensor response towards 100 ppm H<sub>2</sub> at low temperature of 200 °C. Therefore, the porous silicon sensor systems clearly demonstrate a new approach to design and fabricate the low temperature chemiresistive gas sensors with remarkable performance.

## Conflicts of interest

The authors declare no competing financial interests.

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